PATENT

Atty Docket No.: 200315473-1 App. Scr. No.: 10/697,974

## IN THE CLAIMS:

Please find below a listing of all of the pending claims. The statuses of the claims are set forth in parentheses.

1. (Currently amended) A system for delivering material onto a substrate, said system comprising:

a jetting assembly configured to deliver the material to the substrate as droplets; comprising:

a-reservoir-containing-tho-material,-said-reservoir-having-a-nozzlo-through
which-the-material-is-expelled-from-the-reservoir,

an-arcuate-section-positioned-between-the-reservoir-and-the-nozzle,-wherein-the material-is-configured-to-travel-from-the-reservoir,-through-the-arcuate-section,-and-through the-nozzle;

a-means-for-applying-pressure-on-the-material-contained in-the-reservoir;
wherein-the-material-is-expelled-from-the-reservoir-through-application-of-pressure-by-the
means-for-applying-pressure-to-thereby-create-a-column-of-the-material-from-the-nozzle; and

a-means-for-producing-pressure-modulations-located-proximate-the-nozzle, the means-for-producing-pressure-modulations-being-configured to-substantially-regulate formation-of-droplets-from-the-column-of-the-material;

a charging ring, wherein said droplets are configured to pass through the charging ring, and wherein the charging ring is configured to induce an electrical charge to selective ones of the droplets; [[and]]

one or more deflection plates for altering a trajectory of the charged droplets;

a support plate configured to support the substrate; and

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an electrostatic potential delivery device for delivering electrostatic potential to the support plate, wherein delivery of electrostatic potential to the support plate operates to vary the velocities at which the droplets impact the substrate.

2 (Currently granded) The system parenties to state \$51332 and anti- anti-